

U.S.S.N. 09/975,786
Filed: October 11, 2001
AMENDMENT &
RESPONSE TO OFFICE ACTION

Amendments to the Claims

This listing of claims will replace all prior versions, and listings, of claims in the application:

Listing of Claims:

1. (Original) A method for enhancing corrosion of an electrode in a biocompatible fluid, the method comprising:
placing a primary electrode and a counter electrode in contact with an electroconductive biocompatible fluid to form an electrochemical cell; and
applying a time-varying potential, through the electrochemical cell, to the primary electrode,
wherein the potential is characterized by a waveform having a maximum potential effectively anodic to meet or exceed the corrosion potential of the primary electrode, thereby corroding the primary electrode.
2. (Original) The method of claim 1, wherein the primary electrode is a metal electrode.
3. (Original) The method of claim 2, wherein the waveform has a minimum potential effectively cathodic to be below the value where re-deposition of metal ions on the metal electrode can substantially occur.
4. (Original) The method of claim 2, wherein the metal electrode comprises a metal selected from the group consisting of gold, platinum, silver, aluminum, chromium, copper, molybdenum, nickel, palladium, tantalum, titanium, tungsten, and zinc.
5. (Original) The method of claim 1, wherein the primary electrode has a thickness between about 100 and 1000 nm.
6. (Original) The method of claim 1, wherein the primary electrode comprises a reservoir cap of a microchip device for the release of molecules or exposure of device reservoir contents.

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7. (Original) The method of claim 1, wherein the primary electrode comprises a polymer.
8. (Original) The method of claim 1, wherein the biocompatible fluid is a biological fluid.
9. (Original) The method of claim 8, wherein the biological fluid is selected from the group consisting of blood, plasma, lymph, extracellular matrix, interstitial fluid, serum, saliva, cerebrospinal fluid, gastrointestinal fluids, semen, and urine.
10. (Original) The method of claim 1, wherein the biocompatible fluid is selected from the group consisting of saline solutions, buffer solutions, pharmaceutical carrier solutions, and fermentation broths.
11. (Original) The method of claim 1, wherein the biocompatible fluid is *in vitro*.
12. (Original) The method of claim 1, wherein the biocompatible fluid is *in vivo* in a human or animal.
13. (Original) The method of claim 1, wherein the electrochemical cell consists of two electrodes.
14. (Original) The method of claim 1, wherein the electrochemical cell further comprises a reference electrode, which is placed in contact with the biocompatible fluid.
15. (Original) The method of claim 1, wherein the waveform is selected from the group consisting of square waves, sine waves, triangle waves, sawtooth waves, and combinations thereof.
16. (Canceled).

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17. (Currently Amended) A microchip device for the release or exposure of reservoir contents comprising:

a substrate having reservoirs containing contents, wherein the reservoirs have reservoir caps which comprise a primary electrode; and

~~a means~~ controlled-potential instrumentation for applying a time-varying potential at a frequency between about 0.1 and 10,000 Hz to the primary electrode in an amount effective to corrode the primary electrode when placed in contact with an electroconductive fluid, said ~~means~~ instrumentation comprising a counter electrode.

18. (Original) The microchip device of claim 17, wherein the time-varying potential is characterized by a waveform having a maximum potential effectively anodic to meet or exceed the corrosion potential of the primary electrode.

19. (Original) The microchip device of claim 17, wherein the primary electrode is a metal electrode.

20. (Original) The microchip device of claim 19, wherein the waveform has a minimum potential effectively cathodic to be below the value where re-deposition of metal ions on the metal electrode can substantially occur.

21. (Original) The microchip device of claim 19, wherein the metal electrode comprises a metal selected from the group consisting of gold, platinum, silver, aluminum, chromium, copper, molybdenum, nickel, palladium, tantalum, titanium, tungsten, and zinc.

22. (Original) The microchip device of claim 17, wherein the primary electrode comprises a polymer.

23. (Currently Amended) The microchip device of claim 17, wherein the ~~means~~ instrumentation for applying a time-varying potential further comprises a reference electrode.

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24. (Original) The microchip device of claim 17, wherein the primary electrode has a thickness between about 100 and 1000 nm.
25. (Original) The microchip device of claim 17, wherein the reservoir contents comprise a drug, a biosensor, or a combination thereof.
26. (Currently Amended) A method of releasing or exposing the reservoir contents of a microchip device at a site, the method comprising:
providing ~~the microchip device of claim 17~~ at a site a device which comprises
a substrate,
at least two reservoirs in the substrate,
reservoir contents in each of the at least two reservoirs,
at least two reservoir caps, each reservoir cap covering one of the at least
two reservoirs and comprising a primary electrode, and
controlled-potential instrumentation, which comprises a counter electrode,
for applying a time-varying potential at a frequency between about 0.1 and 10,000
Hz to the primary electrode;
placing the primary electrode and the counter electrode in contact with an
electroconductive fluid to form an electrochemical cell; and
applying a time-varying potential, through the electrochemical cell, to the primary
electrode to corrode the primary electrode in an amount effective to disintegrate the reservoir cap
and release or expose the reservoir contents.
27. (Original) The method of claim 26, wherein the potential is characterized by a waveform
having a maximum potential effectively anodic to meet or exceed the corrosion potential of the
primary electrode.
28. (Original) The method of claim 26, wherein the primary electrode is a metal electrode.

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29. (Original) The method of claim 28, wherein the waveform has a minimum potential effectively cathodic to be below the value where re-deposition of metal ions on the metal electrode can substantially occur.
30. (Original) The method of claim 26, wherein the electroconductive fluid is a biocompatible fluid.
31. (Original) The method of claim 30, wherein the electroconductive fluid is a biological fluid.
32. (Original) The method of claim 31, wherein the biological fluid is selected from the group consisting of blood, plasma, lymph, extracellular matrix, interstitial fluid, serum, saliva, cerebrospinal fluid, gastrointestinal fluids, semen, and urine.
33. (Original) The method of claim 30, wherein the biocompatible fluid is selected from the group consisting of saline solutions, buffer solutions, pharmaceutical carrier solutions, and fermentation broths.
34. (Original) The method of claim 26, wherein the electroconductive fluid is *in vivo* in a human or animal.
35. (Previously Presented) A method for enhancing corrosion of an electrode in a biocompatible fluid, the method comprising:
 placing a primary electrode and a counter electrode in contact with an electroconductive biocompatible fluid to form an electrochemical cell; and
 applying a time-varying potential, at a frequency between about 0.1 and 10,000 Hz, through the electrochemical cell, to the primary electrode,
 wherein the potential is characterized by a waveform having a maximum potential effectively anodic to meet or exceed the corrosion potential of the primary electrode, thereby corroding the primary electrode.

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36. (Previously Presented) The method of claim 35, wherein the time-varying potential is applied at a frequency between about 1 and 100 Hz.

37. (Previously Presented) The method of claim 35, wherein the time-varying potential is applied at a frequency between about 1 and 10 Hz.

38. (Previously Presented) A method of releasing or exposing the reservoir contents of a microchip device at a site, the method comprising:

providing at a site a microchip device which comprises (i) a substrate having reservoirs containing contents covered by reservoir caps which comprise a primary electrode, and (ii) means for applying a time-varying potential to the primary electrode in an amount effective to corrode the primary electrode when placed in contact with an electroconductive fluid, said means comprising a counter electrode;

placing the primary electrode and the counter electrode in contact with an electroconductive fluid to form an electrochemical cell; and

applying a time-varying potential at a frequency between about 0.1 and 10,000 Hz. through the electrochemical cell, to the primary electrode to corrode the primary electrode in an amount effective to disintegrate the reservoir cap and release or expose the reservoir contents.

39. (Previously Presented) The method of claim 38, wherein the time-varying potential is applied at a frequency between about 1 and 100 Hz.

40. (Previously Presented) The method of claim 38, wherein the time-varying potential is applied at a frequency between about 1 and 10 Hz.

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41. (New) A device for the release or exposure of reservoir contents comprising:
- a substrate;
 - at least two reservoirs in the substrate;
 - reservoir contents in each of the at least two reservoirs;
 - at least two reservoir caps, each reservoir cap covering one of the at least two reservoirs and comprising a primary electrode; and
 - controlled-potential instrumentation for applying a time-varying potential to the primary electrode to corrode the primary electrode when placed in contact with an electroconductive fluid, wherein the controlled-potential instrumentation comprises a waveform generator and a potentiostat.